Exploring novel materials for future electronic devices Multi technique approach for synthesis and characterization of 2D TMDCs



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Two dimensional transition metal dichalcogenides (TMDCs) have captured the interest of materials science research due to their outstanding properties and prospective applications in next generation devices.^[1] Here we present the growth and characterisation of MoS₂ and WS₂ which are the most well-known TMDC materials.

They are part of the family of the 2D materials presenting a variety of properties.

- energy band gap depending on the structure and the number of layers
- valley polarization due to absence of inversion symmetry and strong spin-orbit interactions

TMDCs Transition metal dichalcogenides

Two dimensional TMDCs monolayers are atomically thin crystalline materials of the type M_2 ,

Where one layer of transition metal (M = Mo, W etc.) atoms is sandwiched between two layers of chalcogen (\times = S, Se etc.) atoms.

existence of stable structures

TMDC-based piezoelectronics

self-powering nano-robots and body-implanted devices^[2]

Low-power and highperformance integrated circuits nanoscale circuits contributing towards green electronics^[3]

Sensors

enhanced sensitivity to functionalisation^[4]

Optoelectronics

direct band gap in near Infrared and visible range^[5]

Valleytronics

degenerate valleys of energy bands well separated in momentum space^[6]

Fast XPS - investigation of the growth of MoS₂ on Au(111)

Fast-XPS (X-ray Photoelectron Spectroscopy) allows to

- monitor the sample growth in real time.
- study the growth dynamics.
- avoid the growth of unwanted species by carefully tuning the growth parameters.

Mo 3d and S 2p core level spectra simultaneously acquired for the study of the growth of single layer MoS₂.^[7]



Temperature (K)





_ S1

S2

HR-XPS is

- element specific and quantitative.
- sensitive to chemical snd structural environment.

High resolution spectra of Mo 3d, S 2p and W 4f show the core level components of single layer MoS_2 and WS_2 .

High resolution XPS





Binding Energy (eV)



T = 340 K 164 163 162 161 160 161

T = 823 K

′ = 810 K

T = 715 K

units)

Binding Energy (eV)

bottomost layer

Structure determination: X-ray Photoelectron Diffraction

163 162





Low Energy Electron Diffraction

LEED is used to determine long range order. MoS₂ study symmetry and rotational alignment of the adsorbate LEED image (at 117eV) for MoS₂ on Au(111) showing the moiré pattern due to lattice mismatch between MoS₂ and the substrate.

Scanning Tunnelling Microscopy

The atomically-resolved STM image on the top shows the



W 4f (K.E. = 130eV)

topmost S atoms exhibiting moiré periodicity of 3.4 nm, visible in the form of bright hexagonal protrusions.

Image at the bottom shows the single layer MoS₂ nano-island carpeting over an Ag terrace.



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